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Sub C3 → -- 28. An electrooptical device according to Claim 3, wherein at least one of the first and the second metal layer has a single layer structure or a lamination structure.--

--29. An electrooptical device according to Claim 3, wherein the first metal layer is made of a material selected from the group consisting of Ti, Cr, Ta, W, Mo, Nb and Si, and the second metal layer is made of a material selected from the group consisting of Al, Cu, Ag, and metal films mainly containing those elements.--

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BRIEF DESCRIPTION --30. An electrooptical device according to Claim 2, wherein the insulating layer is an organic resin film of at least one material selected from the group consisting of polyimide, polyamide, polyimide amide, and acryl.--

--31. An electrooptical device according to Claim 3, wherein the insulating layer is an organic resin film of at least one material selected from the group consisting of polyimide, polyamide, polyimide amide, and acryl.--

--32. An electrooptical device according to Claim 2 wherein the insulating layer is a light absorbing layer.--

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--33. An electrooptical device according to Claim 3 wherein the insulating layer is a light absorbing layer.--

Sub C4 → --34. An electronic equipment comprising an electrooptical device according to Claim 2 as a display.--